RESPONSE UNDER 37 C.F.R. § 1.116 **EXPEDITED PROEDURE EXAMINING GROUP 2814** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Cyril Cabral, Jr., et al.

Examiner: Long Pham

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Mail Stop: Amendment Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated January 3, 2006, applicants submit the following amendments and remarks for entry into the record of the above-identified patent application.

## CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that this document is being filed in the United States Patent and Trademark Office on the date shown below via facsimile transmission to Mail Stop Amendment, Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450 at United States Patent and Trademark Office facsimile transmission number (571) 273-8300.

Dated: March 3, 2006

Leslie S. Szivos

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